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U.S. UTILITY Patent Application

APPL NUM 10071869	FILING DATE 02/08/2002	CLASS 438	SUBCLASS 437	GAU 2842	1742 56	EXAMINER MOT, 110 (77256)
<b>**APPLICANTS:</b> Lin Yixing; West Brian; Wang Hong; Wu Shun; Sun Jennifer; Stow Clifford; Thach Senh;						
<b>**CONTINUING DATA VERIFIED:</b>						
<b>** FOREIGN APPLICATIONS VERIFIED:</b>						
PG-PUB		DO NOT PUBLISH <input type="checkbox"/>		RESCIND <input type="checkbox"/>		
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no				ATTORNEY DOCKET NO		
35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no				006846 USA/CPS/IBSS		
Verified and Acknowledged Examiners's initials						
TITLE : Halogen-resistant, anodized aluminum for use in semiconductor processing apparatus						
U.S. DEPT. OF COMM./PAT & TM-PTO-436L (Rev. 12-94)						

<b>NOTICE OF ALLOWANCE MAILED</b>		<b>CLAIMS ALLOWED</b>	
		Assistant Examiner	
<b>ISSUE FEE</b>		<b>DRAWING</b>	
Amount Due	Date Paid	Sheets Drwg.	Figs.Drwg.
		Print Fig.	
<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>		Primary Examiner	
		Application Examiner	
		<b>PREPARED FOR ISSUE</b>	
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